Group name: Solitude Ensemble

Group member's details

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Problem Description:

• In the fourth week of the project, we delved into exploratory data analysis (EDA) to gain insights into the characteristics and distribution of the data.

- The objective is to understand the underlying patterns, trends, and challenges in the dataset, which are crucial for developing an effective hate speech detection model.
- EDA helps us identify potential biases, class imbalances, and anomalies in the data, guiding preprocessing and modeling decisions to improve the performance and fairness of the model.

EDA Process:

- **Data Overview:** Start by obtaining a high-level overview of the dataset, including its size, structure, and basic statistics.
- **Class Distribution:** Analyze the distribution of hate speech and non-hate speech instances to assess class balance or imbalance.
- **Text Length Distribution:** Investigate the distribution of text lengths (e.g., character count, word count) in hate speech and non-hate speech categories.
- Word Frequency Analysis: Identify the most frequent words or phrases in hate speech and non-hate speech categories to understand common patterns and language usage.
- **Sentiment Analysis:** Conduct sentiment analysis to explore the overall sentiment of text in hate speech and non-hate speech instances.

Insights and Challenges:

- Class Imbalance: Determine if there's a significant class imbalance between hate speech and non-hate speech instances, as this imbalance may affect model training and evaluation.
- **Biases and Anomalies:** Identify any biases or anomalies in the data, such as overrepresentation of certain groups or topics, which may impact the generalizability and fairness of the hate speech detection model.
- Language Characteristics: Gain insights into the linguistic characteristics of hate speech, including the use of offensive language, slang, or discriminatory terms, to inform feature engineering and preprocessing strategies.